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ALD-Grown SnO₂ as an Electron Selective Layer for Perovskite/Silicon Tandem Solar Cells

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Context

Spin-coating of SnO₂ nanoparticles

→ Not adapted

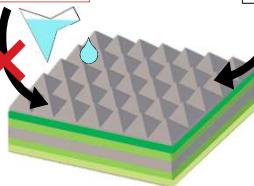


Fig. 1: Schematic of a pyramidal texture of a Si-HJT used as bottom-cell in perovskite/Si tandem cells

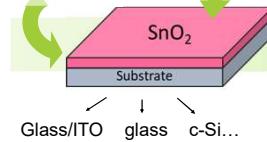
Atomic Layer Deposition (ALD) of SnO₂

→ Conformal & homogeneous

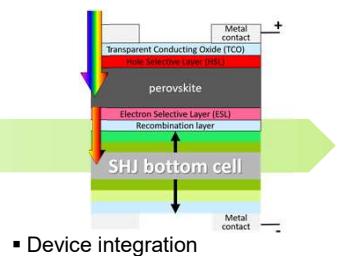
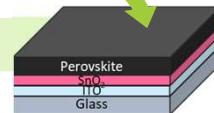
→ Low T

Project summary

- ALD of tin oxide



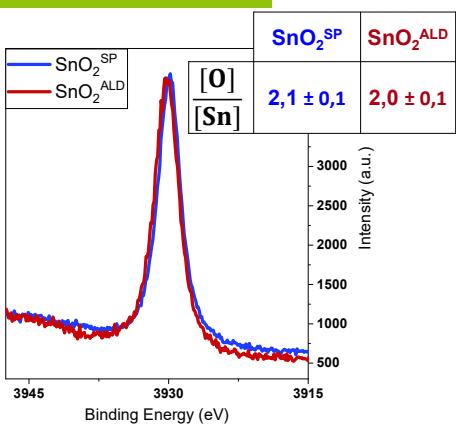
- Thin films characterizations



- Device integration

Goal: Unveiling the charge extraction limitations of a direct SnO₂^{ALD}-perovskite interface

Could it work ?



Behaviour of PK-based solar cells integrating an ALD-grown SnO₂ ESL

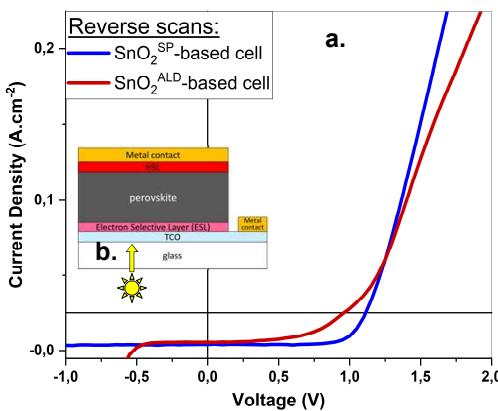


Fig. 4: J(V) characteristics of single-junction (a) and perovskite/silicon tandem (c) cell integrating a reference SnO₂^{SP} ESL and a SnO₂^{ALD} ESL. In inset of each graph, a schematic of a NIP single junction perovskite cell (b) and of a 2-terminal perovskite/silicon tandem cell (d) is shown.

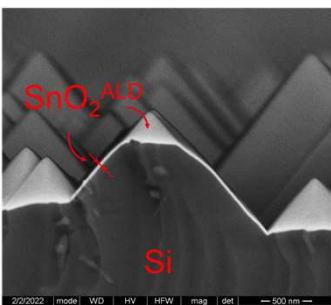
ALD-grown oxide stoichiometry checked

Poor electron extraction & weak electron selectivity

Limitations at SnO₂^{ALD}/Perovskite interface

Perovskite grown on SnO₂^{ALD} VS SnO₂^{SP}?

→ same optical bandgap, topography and crystalline structure [1]



Dense & conformal ALD of SnO₂

SnO₂^{ALD} transparent and highly conductive → [1]

Interface Analysis

Table 1: Workfunction of SnO₂^{ALD} & SnO₂^{SP} layers extracted from KPFM measurements

	SnO ₂ ^{SP}	SnO ₂ ^{ALD}
$\langle\Phi\rangle$ (eV)	4,6 ± 0,1	4,9 ± 0,1

$\Delta\Phi \sim 300$ meV

Significant workfunction difference

→ May generate an electron extraction barrier at the SnO₂^{ALD}/Perovskite interface

Conclusion and perspectives

- Successful growth of SnO₂ by ALD
- Perovskite & perovskite/silicon tandem solar cells with an SnO₂^{ALD}-based ESL show strong performance losses
- KPFM measurements unveiled a significant workfunction difference between SnO₂^{ALD} layers and reference SnO₂^{SP} films
- Chemical characterisation of the SnO₂^{ALD}/Perovskite interface may give further insight on the poor electron selectivity in devices

[1] Gayot et al., DOI:10.4229/EUPVSEC20212021-3BV.1.5

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